

--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--	--

NOIDA INSTITUTE OF ENGINEERING AND TECHNOLOGY, GREATER NOIDA

(An Autonomous Institute Affiliated to AKTU, Lucknow)

M.Tech.

SEM: II - THEORY EXAMINATION (2021 - 2022)

Subject: Nanoscale Devices: Modeling & Simulation

Time: 3 Hours

Max. Marks: 70

General Instructions:

1. The question paper comprises three sections, A, B, and C. You are expected to answer them as directed.
2. Section A - Question No- 1 is 1 marker & Question No- 2 carries 2 marks each.
3. Section B - Question No-3 is based on external choice carrying 4 marks each.
4. Section C - Questions No. 4-8 are within unit choice questions carrying 7 marks each.
5. No sheet should be left blank. Any written material after a blank sheet will not be evaluated/checked.

SECTION A

15

1. Attempt all parts:-

- 1-a. The short-channel effects are attributed to a physical phenomenon (CO1) 1
- (a) the limitation imposed on electron drift characteristics in the channel only
 - (b) the modification of the threshold voltage due to the shortening channel length only
 - (c) Both a & b
 - (d) None of these
- 1-b. The Poisson-Boltzmann equation is a..... (CO2) 1
- (a) nonlinear differential equation
 - (b) linear differential equation
 - (c) linear equation
 - (d) None of these
- 1-c. In how many methods the CNT can be prepared? (CO3) 1
- (a) 1
 - (b) 2
 - (c) 3
 - (d) 4

- 1-d. FinFET was developed to overcome the....(CO4) 1
- (a) short-channel effect
 - (b) large-channel effect
 - (c) mid-channel effect
 - (d) no channel effect
- 1-e. A transconductance amplifier is also called _____. (CO5) 1
- (a) current to voltage convertor
 - (b) voltage to current convertor
 - (c) resistor
 - (d) inductor

2. Attempt all parts:-

- 2.a. What is Quantum effects? (CO1) 2
- 2.b. What is the threshold voltage? Write formula for the drain current and threshold voltage. (CO2) 2
- 2.c. What do you understand by quantum mechanical tunnelling effect? (CO3) 2
- 2.d. What is the difference between FinFET and CMOS? (CO4) 2
- 2.e. Give any two advantages of SAR type ADC. (CO5) 2

SECTION B

20

3. Answer any five of the following:-

- 3-a. Write a short note on quantum effect and volume inversion. (CO1) 4
- 3-b. Briefly discuss the velocity saturation due to short channel effect using the suitable diagram. (CO1) 4
- 3-c. Explain the oxide thickness effect in detail with suitable diagram.(CO2) 4
- 3-d. What is the channel length modulation ? Drive the equation for effective channel length.(CO2) 4
- 3.e. Explain mechanical and thermal properties of CNT? (CO3) 4
- 3.f. How to protect the MOS devices from radiation? (CO4) 4
- 3.g. What is a sample and hold circuit? Where it is used? (CO5) 4

SECTION C

35

4. Answer any one of the following:-

- 4-a. What do you mean by drain punch through condition? Explain it with suitable 7

	diagram.(CO1)	
4-b.	What is the significance of interconnects in MOS devices and also enlist its types.(CO1)	7
5.	Answer any <u>one</u> of the following:-	
5-a.	Discuss an asymmetrical operation of DGSOI FETs with suitable diagram.(CO2)	7
5-b.	Write the short note on followings. (CO2)	7
	i) Miller overlap capacitance	
	ii) Transition capacitance	
	iii) Depletion Capacitance	
6.	Answer any <u>one</u> of the following:-	
6-a.	Explain top-down and bottom-up approaches for synthesis of CNTs.(CO3)	7
6-b.	Discuss MOSFETs with 1D and 2D channel and draw the graph of it density of states.(CO3)	7
7.	Answer any <u>one</u> of the following:-	
7-a.	How total ionizing dose effects works in multi-gate devices? Explain in detail with suitable diagram?(CO4)	7
7-b.	Discuss radiation effects in SOI MOSFETs in detail with suitable diagram.(CO4)	7
8.	Answer any <u>one</u> of the following:-	
8-a.	What is multi-VT devices? Explain in detail? (CO5)	7
8-b.	Discuss the operation of VCO and LNA and also write the designing step for LNA.(CO5)	7